

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Crocker et al.
Title: Nanometer-Scale Engineered Structures,
Methods and Apparatus for Fabrication thereof,
and Applications to Mask Repair,
Enhancement, and Fabrication
Appl. No.: 10/689,547
Filing Date: 10/21/2003
Examiner: Ruggles
Art Unit: 1756

TRANSMITTAL OF CORRECTED FORMAL REPLACEMENT FIGURES

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Transmitted herewith are the corrected formal replacement figures (1-2 sheets, Figures 19 and 21) in response to the Examiner's objection in the above-identified application. Applicants submit that the attached replacement figures overcome the objections raised by the Examiner in the January 19, 2007 office action.

Respectfully submitted,

Date June 4, 2007

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